



Tig.3

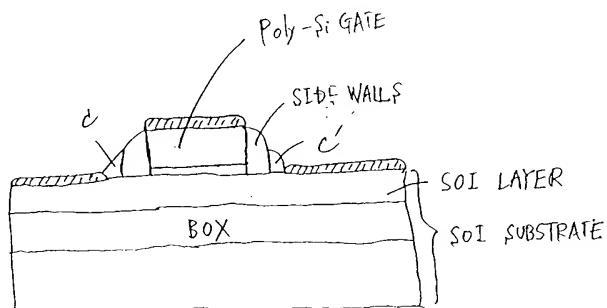




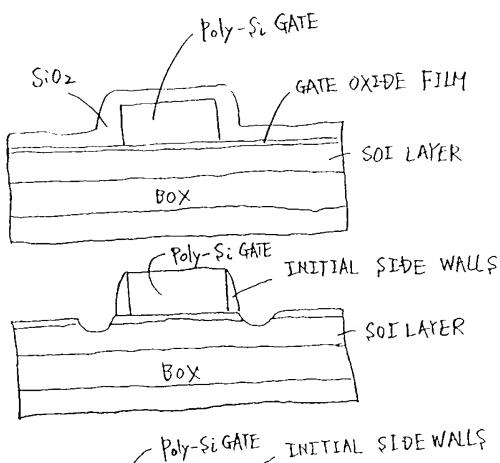
Fig. A

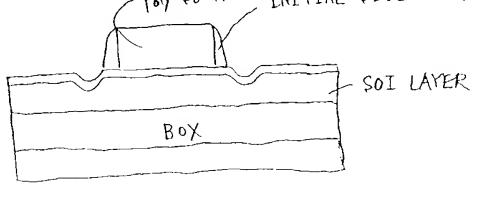
(2)

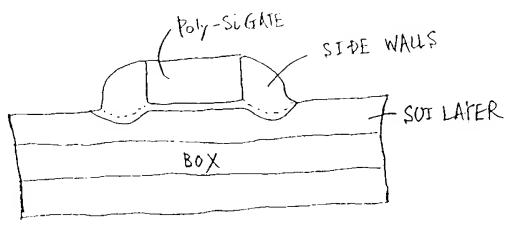
(3)

(4)

(5)







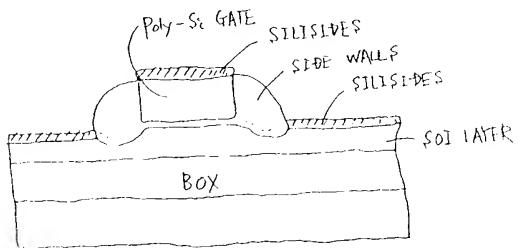




Fig. 5

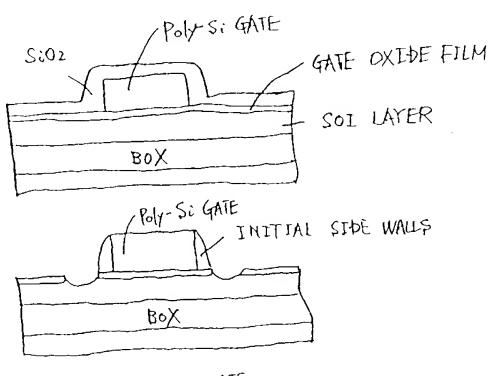
(2)

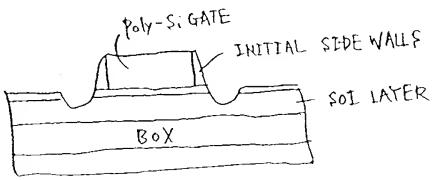
(3)

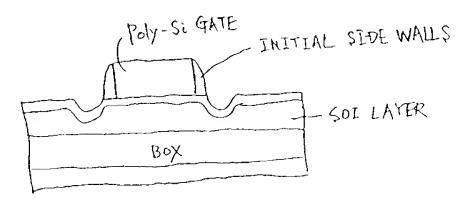
(4)

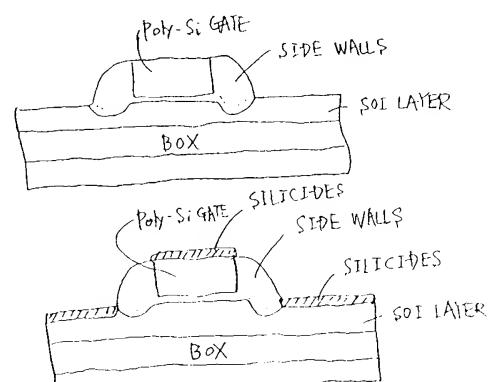
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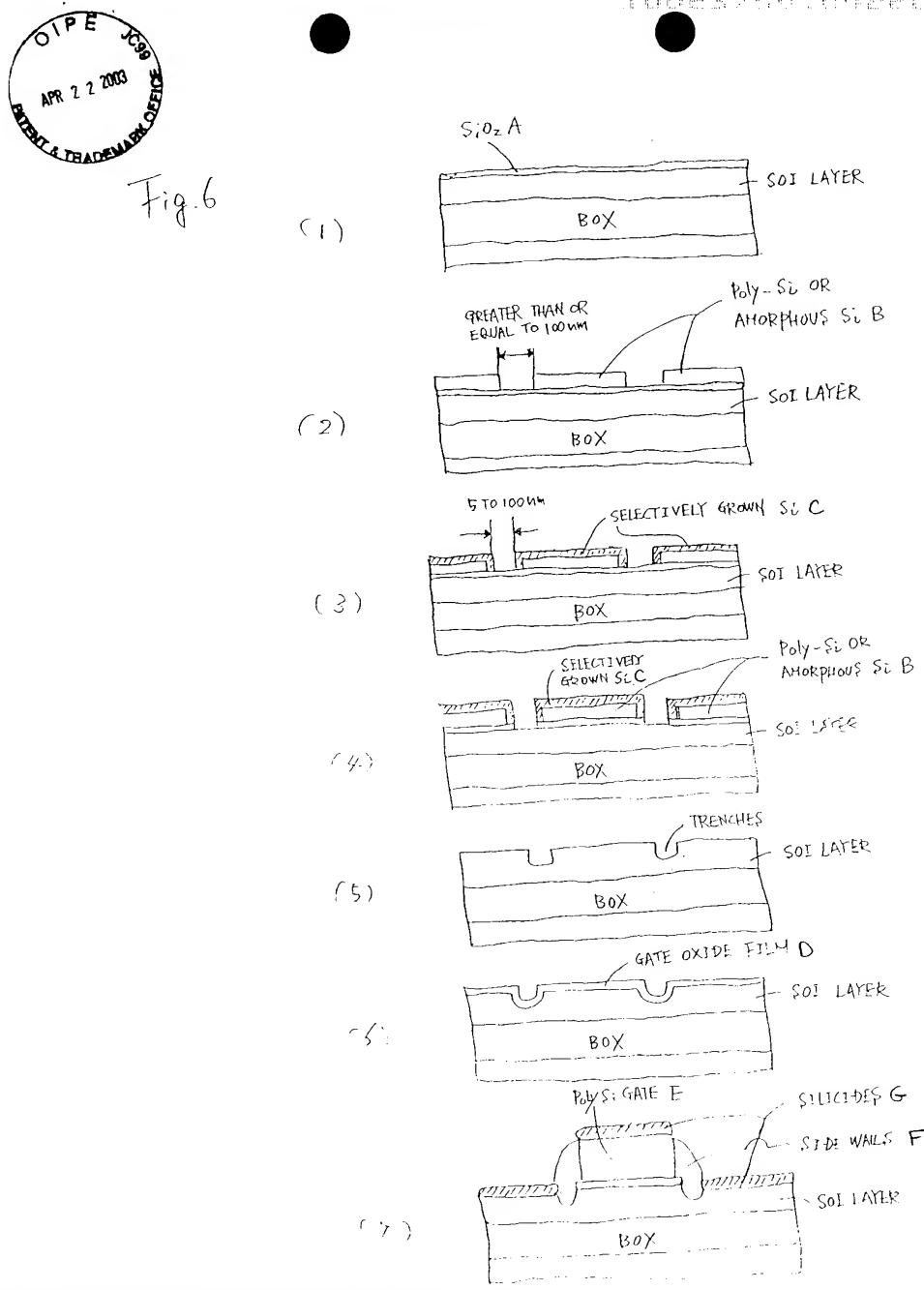
(6)

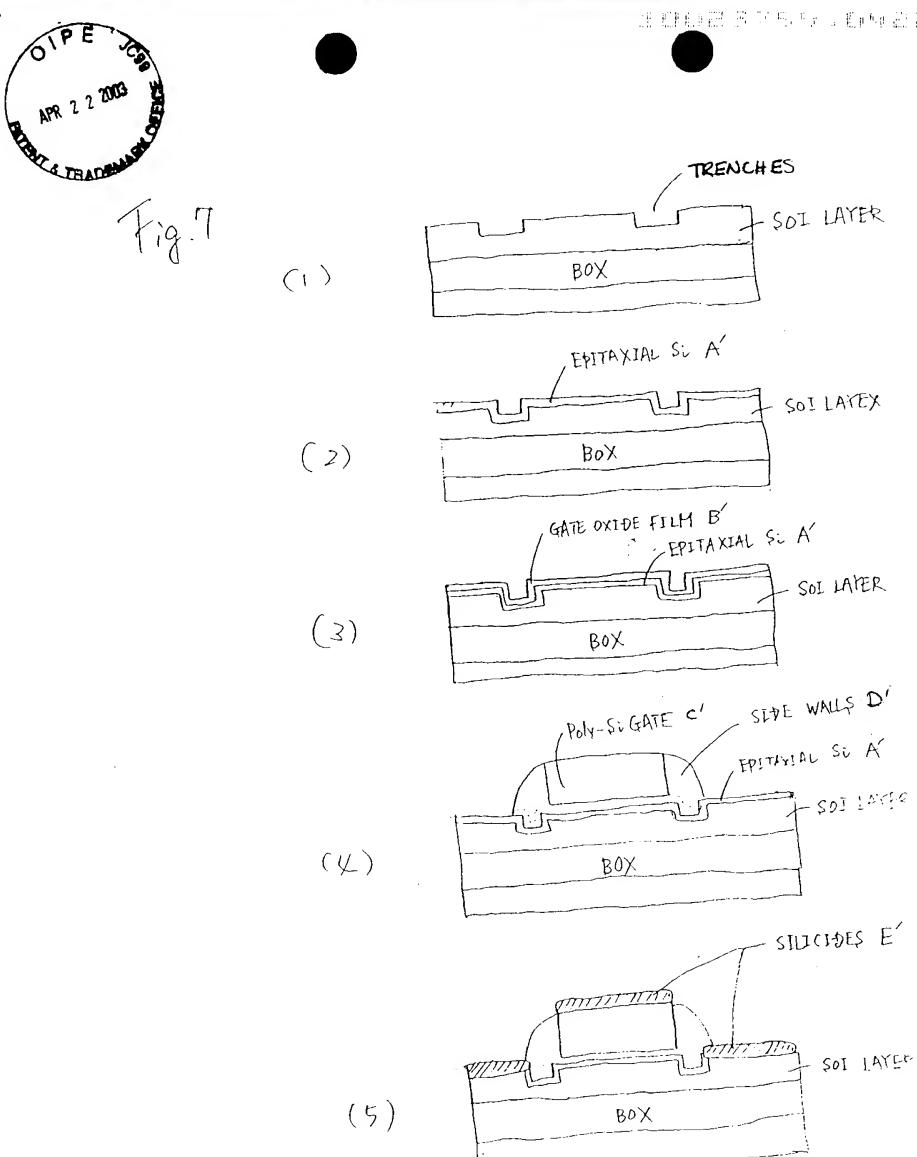










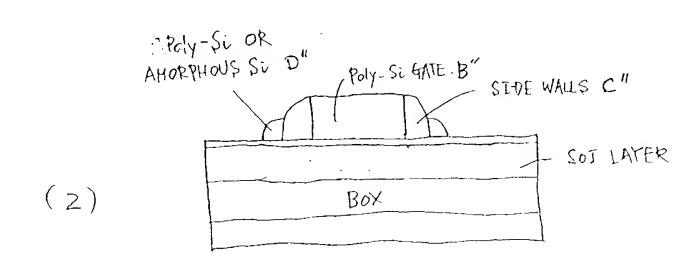


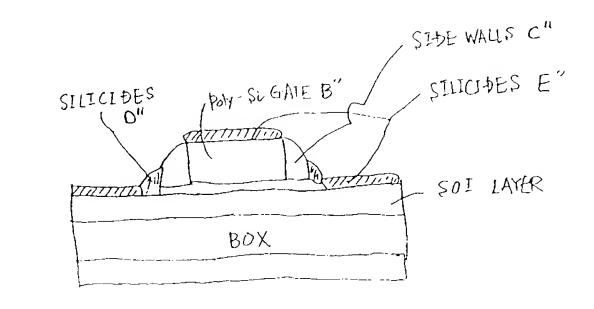
RAPR 22 2000 Fig. 8

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toly-si or Amorphous Si D" Pay-S: GATE ELECTRODE B"

SIDE WALLS C" GATE OXIDE FRUM A" SOI LAYER Box





(3)